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Sheet 1 of 3

FORM PTO-1449	Atty. Docket No.: 19.12-0038	Appl. No.: 09/715,935
LIST OF PATENTS AND PUBLICATIONS FOR APPLICANT'S INFORMATION DISCLOSURE STATEMENT	First Named Inventor:	
	Xiangxin Bi, et al.	
	Filing Date November 17, 2000	Group Art: ---

U.S. PATENT DOCUMENTS

Examiner Initial	Document No.	Date	Name	Class	Sub Class	Filing Date If Appropriate	
EF	AA	3,806,570	4-23-74	Flamenbaum et al.	264	66	3/30/72
EF	AB	3,923,484	12-2-75	Randall	65	18	1/11/74
EF	AC	3,883,336	5-13-75	Randall	65	18	1/11/74
EF	AD	3,932,162	1-13-76	Blankenship	65	3	6/21/74
EF	AE	3,934,061	1-20-76	Keck et al.	427	165	7/18/73
EF	AF	4,038,370	7-26-77	Tokimoto et al.	423	336	9/23/75
EF	AG	4,112,844	9-12-78	Tokimoto et al.	423	336	10/18/1976
EF	AH	4,735,677	4-5-88	Kawachi et al.	156	633	4/2/87
EF	AI	4,814,289	3-21-89	Baeuerle	437	060	12/21/87
EF	AJ	4,868,005	9-19-89	Ehrlich et al.	427	53.1	3/10/88
EF	AK	5,060,595	10-29-91	Ziv et al.	118	722	4/23/90

FOREIGN PATENT DOCUMENTS

		Document No.	Date	Country	Class	Sub Class	Translation Yes No
EF	AL	WO 99/23189	14-5-99	PCT	—	—	—
EF	AM	WO 99/61244	2-12-99	PCT	—	—	—
	AN						

OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)

EF	AO	High-silica cascaded three-waveguide couplers for wideband filtering by Flame Hydrolysis on Si, G. Barbarossa, P.J.R. Laybourn, SPIE Vol. 1583 Integrated Optical Circuits (1991) Pgs. 122-128.
EF	AP	High-silica low-loss three waveguide couplers on Si by Flame Hydrolysis Deposition, G. Barbarossa, P.J.R. Laybourn, SPIE Vol. 1513 Glasses for Optoelectronics II (1991) pgs. 37-43.
EF	AQ	Recent advances in the fabrication of hollow glass waveguides, C.D.Rabii, D. Dobin, D. Gibson, and J.A. Harrington, SPIE Vol. 3262 pgs. 103-107. (1998)

EXAMINER: [Signature] DATE CONSIDERED: 10/3/01

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.



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EP	AR	5,108,952	4-28-92	Matsushashi	437	192	7/30/90
EF	AS	5,276,012	1-4-94	Ushida et al.	505	1	2/11/92
EF	AT	5,385,594	1-31-95	Kanamori et al.	65	60.2	12/4/92
EF	AU	5,551,966	9-3-96	Hirose et al.	65	377	1/13/94
EF	AV	5,556,442	9-17-96	Kanamori et al.	65	17.4	6/23/94
EF	AW	5,622,750	4-22-97	Kilian et al.	427	163.2	10/31/94
EF	AX	5,863,604	1-26-99	Hunt et al.	427	248.1	3/28/97
EF	AY	5,885,904	3-23-99	Mehta et al.	438	758	2/14/97
EF	AZ	5,958,348	9-28-99	Bi et al.	422	186.04	2/28/97
EF	BA	5,997,956	12-7-99	Hunt et al.	427	450	8/2/96
EF	BB	6,011,981	1-4-00	Alvarez et al.	505	190	3/10/97

FOREIGN PATENT DOCUMENTS

	Document No.	Date	Country	Class	Sub Class	Translation Yes No
BC						
BD						
BE						

OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)

EF	BF	Laser synthesize silicon-based and ferro-based nano powders, Yong Liang, Zhengang Wu, Zheng Feng, Quangang Xian, SPIE Vol. 3862 pgs. 17-21. (1999)
EF	BG	Optical damage threshold of P ₂ O ₅ and GeO ₂ -P ₂ O ₅ -doped silica waveguides, G. Barbarossa, P.J.R. Laybourn, SPIE Vol. 1794 Integrated Optical Circuits II (1992) pgs. 185-190.
EF	BH	Effect of temperature gradient on sintering kinetics of doped silica waveguides by flame hydrolysis deposition, G. Barbarossa, P.J.R. Laybourn, SPIE Vol. 1794 Integrated Optical Circuits II (1992) pgs. 191-197.

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	BI					
	BJ					
	BK					
	BL					
	BM					
	BN					

FOREIGN PATENT DOCUMENTS

	Document No.	Date	Country	Class	Sub Class	Translation Yes No
	BO					
	BP					

OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)

EF	BQ	Photosensitivity & rare-earth doping in flame hydrolysis deposited planar silica waveguides, Graeme D. Maxwell, SPIE Vol. 2695 pgs. 16-29. (1996)
EF	BR	Building passive components with silica waveguides, C. Jacob Sun and Kevin M. Schmidt, SPIE Vol. 3795 p. 313-319. (July 1999)
EF	BS	Laser distillation-deposition synthesis of silica glasses with variable concentrations of oxygen deficient centers. v.f.Lebedev, V.M.Marchenko, A.O. Rybaltovski, V.A. Tikhomirov. SPIE Vol. 2498. pgs 6-71 (1995)
EF	BT	Center for Nano Particle Control; Web Site Mansoo CHOI, Associate Professor of Mechanized Engineering, Seoul National University, June, 2000.

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